

**AMENDMENTS TO THE SPECIFICATION**

**Please amend the specification by adding the following before paragraph no. [0001]:**

**CROSS-REFERENCE TO RELATED APPLICATIONS**

This application is a National Stage Entry of International Application No. PCT/EP2004/010188, filed on September 13, 2004 in the European Patent Office. This application claims priority from DE 103 43 333.3, filed on September 12, 2003 in the German Patent Office, and DE 10 2004 010 571.5, filed on February 26, 2004 in the German Patent Office. The entire disclosures of the prior applications are hereby incorporated by reference.

**BACKGROUND OF THE INVENTION**

1. Field of the Invention

**Please amend the specification by adding the following before paragraph no. [0002]:**

2. Description of the Related Art

**Please amend the specification by adding the following before paragraph no. [0008]:**

**SUMMARY OF THE INVENTION**

**Please amend the specification by adding the following before paragraph no. [0036]:**

**BRIEF DESCRIPTION OF THE DRAWINGS**

**Please amend the specification by adding the following before paragraph no. [0037]:**

DETAILED DESCRIPTION OF EXEMPLARY EMBODIMENTS OF THE INVENTION

**Please replace the paragraph no. [0007] with the following amended paragraph:**

DE 199 44 760 A1 discloses an illumination device for printing plates which permits modulation of the illumination intensity in the integrated digital screen imaging process (IDSi). In this case, the light from a light source falls onto a digital light modulator having a two-dimensional array of cells, which can be activated and deactivated via a computer-controlled system in order to deflect a specific pattern onto a light-sensitive substrate, which is moved relative to the light modulator. In one embodiment, the light modulator comprises a micro mirror arrangement (digital mirror device, DMD) having a large number of individual mirrors that can be driven individually. During printing, those mirrors which are not used for the exposure of the light-sensitive material are tilted in such a way that they deflect the light beam falling on them away from light-sensitive material. By means of the control system, the number of individual mirrors used in the exposure is thus changed. A similar system is disclosed by ~~WO 01/36470 A2~~ WO 00/36470.